

IPCN



PATENT

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re the application of: Sang Kuk CHOI, et al.

Serial No.: 10/617,703

Group Art Unit: 2881

Filed: July 14, 2003

Examiner: Nguyen, Kiet Tuan

For: DEFLECTOR OF A MICRO-COLUMN ELECTRON BEAM APPARATUS AND  
METHOD FOR FABRICATING THE SAME

\* \* \* \* \*

**RESPONSE TO RESTRICTION REQUIREMENT**

Honorable Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

May 25, 2004

Sir:

In response to the Request for Restriction mailed May 3, 2004 (Paper No. 20040429), Applicant elects Group I, claims 1-5, drawn to a deflector of a micro-column electron beam apparatus, classified in class 250, subclass 396R, without traverse.

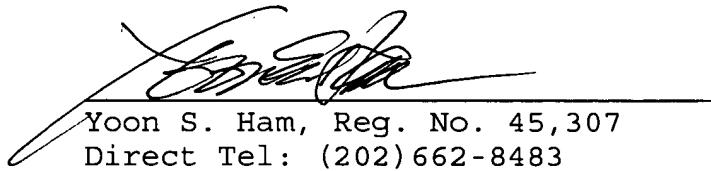
An early Office Action on the merits is respectfully requested.

If a Petition for Extension is necessary and the petition and/or check is not enclosed, this will act as a petition to extend the time for response and authorization to charge the necessary fees under 37 CFR 1.17(a) - (d) to Deposit Account 06-1358.

May 25, 2004

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Atty. Docket No.: P69018US0

Respectfully submitted,



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